

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	5	( (mask near2 (memory or rom)) and gate and polysilicon and implant\$5 and buried and silicide and etch\$3). clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/09/18 21:16